## M.Sc. PHYSICS FOURTH SEMESTER CONDENSED MATTER PHYSICS-II MSP - 401A [USE OMR FOR OBJECTIVE PART]

SET

Duration: 3 hrs.

(Objective)

Time: 30 min.

Full Marks: 70 Marks: 20

## Choose the correct answer from the following:

1X20=20

1. The mobility is defined as

- a. velocity per unit electric field
- c. electric field per unit velocity
- 2. Einstein relation reads as

$$D = \frac{\mu k_B T}{e}$$

a. 
$$D = \frac{\mu k_B T}{e}$$
 c. 
$$D\mu = \frac{k_B T}{e}$$

b. velocity per unit current

- d. current per unit velocity
- 3. For H<sub>2</sub>O, the transition from liquid phase to gaseous phase is a
  - b. Second order transition
  - a. First order transition c. Third order transition
- d. None of these
- 4. n-th order phase transition occurs when the \_ \_th derivative of the Free energy function becomes discontinuous
- n+1
- n-1n - 1, n, n + 1
- 5. The product  $np = n_i^2$ , is a constant, independent of
  - a. temperature

- b. doping
- c. both temperature and doping
- d. none of these
- 6. Negative differential conductance phenomenon is observed in
  - a. photoconductivity

b. Gunn effect

c. thermionic emission

- 7. The mobility of an electron is higher for
  - a. smaller effective mass
- d. Hall effect

b. larger effective mass d. none of these

- c. shorter lifetime
- 8. Fundamental absorption takes place for
- b.

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 $h\nu < E_g$ 

- $h\nu \ll E_g$
- $h\nu \geq E_q$
- d. none of these
- 9. The width of the depletion region
  - a. decreases with increasing the doping concentration
  - c. is independent of doping concentration
- b. decreases with decreasing the doping concentration
- d. None of these

	a. 1 V/cm c. 100 V/cm	b. 10 V/cm d. 1000 V/cm
11.	<ul> <li>In a soap bubble film, the soap molecule is a. hydrophobic outwards, hydrophilic inwards</li> <li>c. both outwards</li> </ul>	arranged such that their ends point towards  b. hydrophobic inwards, hydrophilic outwards  d. both inwards
12.	Vacuum in evaporation technique of film d  a. lowering melting point c. both i and ii	eposition is used for  b. reduction in impurities  d. neither i nor ii
13.	Angular deposition of a film can be regulat a. Ion beam assisted Sputtering c. RF sputtering	ed using the technique of  b. DC Sputtering  d. GLAD sputtering
14.	The relation of momentum transfer in sputs a. $W = \frac{kVi}{P_T d}$ c. $W = \frac{Vid}{kP_T}$	tering process is given by b. $W = \frac{Vi}{kP_Td}$ d. $W = \frac{1}{kP_TVd}$
15.	In MBE, in order to produce precise beams they'rein gas form at the substrate from "gu a. thermal guns c. effusion cells	of atoms/molecules, they are heated up so uns" also called as b. updraft cells d. effusion guns
16. I	n an MBE setup, pyrolitic boron nitride (PB a. high T & low P c. low T & high P	N), is used because it can withstand b. high T & high P d. low T & low P
17.	3D depositions with the help of MBE is pos a. stonger adatom interactions c. stronger adatom-substrate interaction	b. weaker adatom interactions
18.	Pick the top-down approach of nanoparticle a. CVD c. Ball-milling	e synthesis from the techniques below b. Hydrothermal d. None of the above
19. ]	Pick the Botttoms-Up approach of nanopart a. CVD c. Ball-milling	icle synthesis from the techniques below b. Hydrothermal d. None of the above
	The morphological characterization of nan a. XRD c. Raman Scattering	oparticle can be done using b. TEM d. None of the above
20.	C. Kaman Kattering	

## $\left( \, \underline{Descriptive} \, \right)$

Time: 2 hrs. 30 min. Marks: 50

## [Answer question no.1 & any four (4) from the rest]

1.	a. Discuss the diffusion process under different circumstances, namely, (i) behavior of concentration pulse with space at different times, (ii) the same as (i) in the presence of an electric field, and (iii) the same as (i) now with considering recombination.	5+5=10
	b. Draw the various absorption processes involving impurities through the band diagrams.	
2.	a. What are hot electrons?	1+4+5
	<b>b.</b> Show that the temperature of the hot electrons is higher than the lattice temperature.	=10
	c. Discuss Gunn effect with proper diagrams, such as current density as a function of electric field.	
3.	a. Draw the phase diagram of water (P-T curve) and denote the different phase regions.	3+7=10
	b. Consider the condensation of gas into liquid $(P, \rho, T)$ and transformation of paramagnet to ferromagnet $(H, M, T)$ . Discuss the features at the critical points by drawing the different phase diagram of the full 3D phase space of $(P, \rho, T)$ and $(H, M, T)$ .	
4.	a. Discuss the photoconductivity phenomenon with proper diagram.	4+6=10
	b. Find out the excess carriers using the rate equation in terms of the generation rate and recombination process.	
5.	Draw a neat diagram of a typical Molecular Beam epitaxy setup and name its components. Describe the utility of effusion cells and cryogenic sink in MBE.	5+5=10
6.	Mention the steps involved in PVD technique of thin film deposition. Describe how the deposition rate depends on the position of the wafer in PVD technique.	5+5=10

5+5=10

 Describe the working principle of Molecular Beam Epitaxy technique of film growth. Also discuss its advantages over other thin film growth technique.

10

8. Discuss the various methods of nanoparticle synthesis and characterization techniques.

5+5=10

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